

561 AF/2800

ATTORNEY DOCKET NO.
D900 D/1368D

PATENT



-1-

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: : Before the Examiner:
Marina V. Plat et al. : Lee, Hsien Ming

Serial No.: 10/079,775 : Group Art Unit: 2823

Filed: February 19, 2002 :

Title: METHOD AND SYSTEM FOR :
REDUCING ARC LAYER REMOVAL :
OF PHOTORESIST :
:

AMENDMENT TRANSMITTAL

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Mail Stop AF
Commissioner for Patents
P.O. Box 1450
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OK

Sir:

Transmitted herewith is an Amendment Under 37 C.F.R. § 1.116, 2 Executed 131 Declarations and Acknowledgment Postcard for the above-identified Application.

No additional fee is required.
 The fee has been calculated as shown below:

11/15/03

CERTIFICATION UNDER 37 C.F.R. § 1.8

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to Mail Stop AF, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on 11-4, 2003.

Toni Stanley
Signature

Toni Stanley
(Printed name of person certifying)